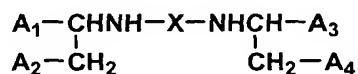


ABSTRACT

Disclosed is a method of processing a light sensitive planographic printing plate precursor comprising a support, and provided thereon, a light sensitive layer and an overcoat layer in that order, the method comprising the steps of imagewise exposing the light sensitive planographic printing plate precursor, pre-washing the exposed light sensitive planographic printing plate precursor with a pre-washing solution in the presence of a compound represented by the following formula (1) or (2), or an N-alkyliminodiacetic acid or its salt, the alkyl having a carbon atom number of 1 to 3, and developing the pre-washed light sensitive planographic printing plate precursor with a developer,

Formula (1)



Formula (2)

